

Observation of narrow-band γ radiation from a boron-doped diamond superlattice with an 855 MeV electron beam

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We report the first observation of narrow-band 1.3 MeV γ radiation from a crystalline diamond microundulator. A diamond superlattice was grown with a periodically varying boron doping profile. Four sinusoidally deformed (110) periods resulted with a period length of 5.0 μm and an amplitude of 0.098 nm. A channeling experiment was performed with the 855 MeV electron beam of the Mainz Microtron MAMI accelerator facility. A clear peak was detected with a large sodium iodide scintillation detector close to the expected photon energy of 1.28 MeV. Key characteristics of the peak, including photon energy, width, and intensity, were reproduced fairly well by Monte Carlo simulation calculations. Based on the latter, optimized boron doping profiles were designed for a hypothetical 3 GeV electron beam, enabling preparation of a highly directional γ -ray beam with a photon energy of 14.5 MeV. The predicted spectral bandwidth is 13%, however, with a high-energy continuum tail. The on-target photon flux at a beam current of 100 μA would be about 10^{12} s^{-1} .

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I. INTRODUCTION

Intense narrow-band multi-MeV photon beams hold significant potential for applications in basic and nuclear research, medicine, and industrial technology [1–5]. Having in mind, in particular, photonuclear reactions for application purposes, the production mechanisms of such beams should be targeted, from an economical point of view, on electron accelerators with moderate energies in the GeV range or below. Bremsstrahlung radiation created by an electron beam incident on a high-Z target has been widely used for many decades. However, such sources feature broadband radiation characteristics. Nearly monoenergetic γ -ray beams of high intensity can be produced by facilities based on laser Compton backscattering, which are already operational [6] or currently under construction (see Table 10 of Ref. [4]).

In this work, an alternative route toward narrow-band photon sources was elaborated, which is based on the channeling process of ultrarelativistic electrons in periodically bent crystals. The method, theoretically known since long

[7,8], has been comprehensively treated in Refs. [9–12] or in monographs [13–15] in which all relevant references can be found. It resembles magnetic undulators, however, with period lengths in the multimicrometer range rather than on a centimeter scale. The principle will be explained by means of Fig. 1. We employ the continuum potential picture introduced by Lindhard [16], applied also in our case study [17] on which this publication is partly based.

An electron entering the crystal at the coordinates $x = z = 0$ nearly parallel to the z axis may be captured in the potential pocket, which at that point is symmetrical with a barrier height of 24 eV. The electron oscillates while following the bent sinusoidal shape of the (110) plane. By means of the accompanied acceleration, channeling radiation and undulatorlike radiation will be emitted. The radiation is strongly forward directed; for undulatorlike radiation, the typical opening angle is on the order of 0.5 mrad for 1 GeV electrons. The photon energies fall into the γ -ray domain, for a period length of a few micrometers typically in the MeV range. It scales with the electron beam energy squared and inversely with the undulator period length λ_U . The capture probability and in turn the intensity of the γ radiation requires high-quality electron beams with a low angular spread. The reason is that the transverse energy $pv/2 \times \vartheta_x^2$ is the initial kinetic energy of the particle in the potential pocket, with pv in essence the electron beam energy and ϑ_x the angle of the electron with respect to the z axis.

The experimental challenge is to fabricate crystalline undulators with such small periods. A graded composition strained layer in a superlattice was proposed [18,19], and $\text{Si}_{1-x}\text{Ge}_x$ undulator crystals were grown at the Aarhus

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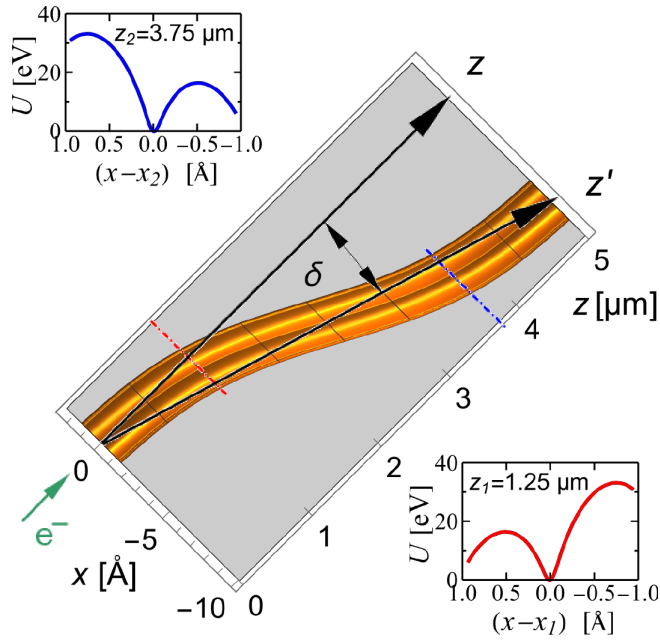


FIG. 1. Transverse potential $U(x, z)$ for a single (110) channel of a boron-doped diamond superlattice. Shown is one period with length of $\lambda = 5.0 \mu\text{m}$. Coordinates (x, z) of a full period $(0, 0)$ and $(-7.50 \text{ Å}, 5 \mu\text{m})$ define the z' undulator direction around the potential wiggles. It makes an angle $\delta = -0.150 \text{ mrad}$ with the z axis, the nominal electron beam direction. Note that the longitudinal z coordinate is squeezed by four orders of magnitude. For details, see Appendix B and also Ref. [20]. Barrier heights are modified as functions of z by centrifugal forces. Insets show examples, $x_1 = -0.898 \text{ Å}$ and $x_2 = -6.604 \text{ Å}$. Figure based on design parameters of Sec. II A.

University. Experiments were performed with an undulator with period length of $9.9 \mu\text{m}$ [21,22] with 270, 375, and 855 MeV electrons at MAMI. Structures at predicted undulator energies were observed and interpreted as originating from synchrotronlike radiation. In Ref. [11], Monte Carlo calculations were performed for the case of 855 MeV, which may corroborate this interpretation. Experiments with an undulator with a period length of $0.43\text{--}0.44 \mu\text{m}$ [23,24] were not convincing enough to be used for applications discussed in Ref. [25], and this route will not be pursued in this paper. Alternatives are diamond undulators that can be produced by chemical vapor deposition (CVD) with periodically varying content of boron. The effect is based on the functional dependence of the lattice constant on the boron content (see, e.g., Fig. 1 of Ref. [26]). Previous attempts to observe undulator radiation from boron-doped diamond structures were unsuccessful [17,27].

In this paper, we report on the first successful observation of narrow-band undulator radiation from a boron-doped diamond superlattice. The parameters of the microundulator, which are quite different in comparison to that reported in Refs. [21,22] for the $\text{Si}_{1-x}\text{Ge}_x$ undulators, are collected in the caption of Fig. 1. In the design of the undulator, we took into account that the low $Z = 6$ material diamond has the advantage, besides its radiation hardness, that scattering by atomic nuclei and electrons comprising the crystal is much smaller in comparison with silicon, $Z = 14$. Scattering may

increase the transverse energy and, in turn, the dechanneling probability. This is the case, in particular, in regions in which the radius of curvature is small; i.e., centrifugal forces are large and one of the barrier heights is low as shown in Fig. 1 at $z_1 = 1.25 \mu\text{m}$ and $z_2 = 3.75 \mu\text{m}$. Therefore, the radius of curvature was kept large resulting in a small oscillation amplitude or, in other words, in a small undulator K parameter resulting in radiation with moderate intensity.

Applications of such γ radiation sources may be placed in the field like nuclear structure research with photonuclear reactions or many others as compiled in Ref. [4].

The paper is organized as follows. In Sec. II, the superlattice is described, including diagnosis of it, and the experimental setup at MAMI. Section III is devoted to the peak search. The result is discussed in Sec. IV by means of a comparison with Monte Carlo simulation calculations. In Sec. V, beam features are sketched for possible future applications. The paper closes in Sec. VI with conclusions. Some details of the superlattice preparation as well as of the Monte Carlo simulation calculations are provided in Appendixes A and B, respectively.

II. EXPERIMENTAL

A. The diamond undulator

Parameters of the diamond superlattice were optimized by means of Monte Carlo simulation calculations for an experiment with an electron beam energy of 855 MeV. The period length must be chosen such that the undulator peak energy is well separated from the channeling radiation distribution. Finally we found the following design parameters: period length in the [100] direction $3.54 \mu\text{m}$, number of periods $N_U = 4$, and amplitude $A_U = 0.098 \text{ nm}$. Details are provided in Appendix A.

The boron doping profile was examined with the time-of-flight secondary ion mass spectrometry (ToF-SIMS) method. Figure 2(a) shows the depth profile. The ToF-SIMS data indicate that the growth process reproduces the four sinusoidal periods, irrespective of the analyzed region. As designed, the layers are consistent with a period length of $3.54 \mu\text{m}$ along the [100] growth direction. A slight variation of the doping maxima and minima from one period to the other can be observed for the layers apart from the substrate.

Figure 2(b) depicts a section of an integrated intensity map of the Bragg peak, taken with the rocking curve imaging (RCI) technique [28,29] at the European Synchrotron Radiation Facility, Grenoble. The structure corresponds to the doping profile of Fig. 2(a). This result has been confirmed over more than 1 mm along the crystal.

B. Experimental setup at MAMI

The experimental setup at the Mainz Microtron MAMI is shown in Fig. 3. The electron beam is focused onto the diamond crystal in the target chamber with a goniometer, and thereafter deflected by a dipole magnet into the beam dump. The target can be rotated in all three spatial directions with an accuracy of $35 \mu\text{rad}$. The target is aligned using the signal of the ionization chamber that registers scattered electrons. The orientation of the electron beam parallel to planes increases the scattering probability and, in turn, the signal of the ioniza-

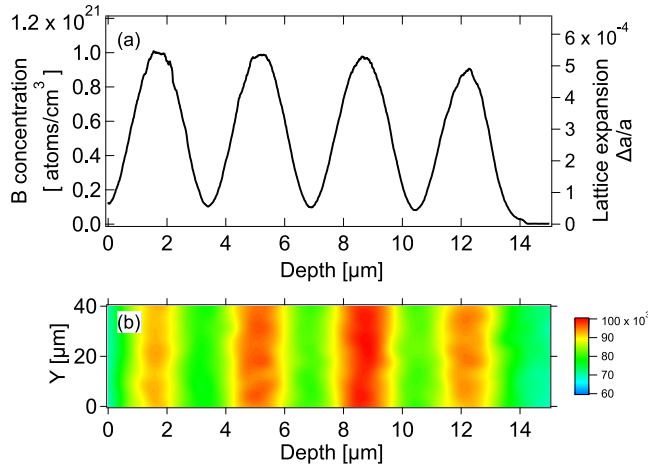


FIG. 2. (a) Measured boron doping profile. A $250 \times 250 \mu\text{m}^2$ crater allowed for the analysis of the material as a function of depth with ToF-SIMS. On the left scale, the boron concentration is shown, on the right one, the corresponding relative lattice expansion $\Delta a/a$, according to the “atomic volume interpolation” [26], also called “modified Vegard’s law.” (b) Depth profile obtained with the RCI technique [28,29]. The signal is the integrated intensity of Bragg-diffraction peaks at (111) planes with 17 keV photons.

tion chamber. This method allows rapid alignment to a crystal plane.

The radiation in the forward direction is detected with a 10 inch sodium iodide crystal, NaI(Tl), positioned at a distance of about 8.5 m from the target. A movable cylindrical tungsten aperture defines the observation direction. It has a length of 261 mm and a bore of 4 mm diameter, which was reduced with an additional 28.8 mm long tungsten cylinder inset with an inner diameter of 2 mm. The alignment of the aperture

was done by maximizing the detected bremsstrahlung from an aluminum foil.

III. MEASUREMENTS AND RESULTS

The peak search was performed at an electron energy of 855 MeV. The angle of the tungsten aperture was varied. There exist two favorable observation angles. One is the direct forward direction $\theta_x = 0$, for which the radiation direction defining aperture is on-axis with the electron beam direction. It is in Fig. 1 the z axis that makes a small angle $\delta_0 = 0.0272$ mrad with the [110] direction of the host crystal due to the small residual boron doping. The other one is the undulator direction in which the aperture is detuned by the angle $\theta_x = \delta = -0.150$ mrad into the z' direction. For both directions, $\theta_y = 0$ was chosen. For details, see Appendix A.

The undulator photon energy can be estimated with the well-known undulator relation

$$\hbar\omega = k \frac{4\pi\gamma^2\hbar c}{\lambda_U(1 + K^2/2 + \gamma^2(\delta - \theta_x)^2 + (\gamma\theta_y)^2)}, \quad (1)$$

with Lorentz factor $\gamma = 1674.2$ for 855 MeV, the reduced Planck constant $\hbar$, and c the speed of light. In lowest order $k = 1$ a peak energy $\hbar\omega = 1.28$ MeV results at observation in the undulator z' direction $\theta_x - \delta = 0$, $\theta_y = 0$. For the undulator amplitude $A_U = 0.0977$ nm, $\lambda_U = 5.0 \mu\text{m}$, the undulator parameter amounts to $K = \gamma \times A_U \times 2\pi/\lambda_U = 0.206$.

Figures 4(a) and 4(b) depict spectra taken with the sodium iodide detector, (c) and (d) results of corresponding simulation calculations.

IV. DISCUSSION

The spectrum in green color of Fig. 4(a) exhibits a clear narrow peak with an energy of 1.30 MeV. It appears only at a negative observation angle $\theta_x = -0.2$ mrad, while at the positive angle of $+0.2$ mrad mainly background is observed; see spectrum in blue color. The result shows that our method for a peak search, as proposed in Fig. 11 of Ref. [17] and applied for an unsuccessful experiment, demonstrates that our method is highly sensitive and enables the creation of a difference spectrum shown in Fig. 4(b). This crucial methodical procedure has not been addressed in Refs. [30,31]; however, features of the experimental observations were predicted. In contrast to the above-mentioned $\text{Si}_{1-x}\text{Ge}_x$ strained layer crystal, the diamond undulator structure cannot be separated from the host diamond crystal. As a consequence, one is always faced with radiation from the backing, the thickness of which can be minimized to values in the several micrometer range. However, in our experiment the thickness in [100] direction was $182 \mu\text{m}$, a rather large value in comparison with the undulator layer thickness of $14.1 \mu\text{m}$. Therefore, a huge channeling radiation contribution is present, although somehow suppressed due to the choice of the observation direction, and consequently, the difference spectrum is afflicted with large uncertainties, in particular, above 2 MeV. The thickness of the substrate can be substantially reduced by nearly two orders of magnitude into the several micrometer region. This can be achieved by laser water jet cutting, followed by quantum polishing to smooth the back surface.

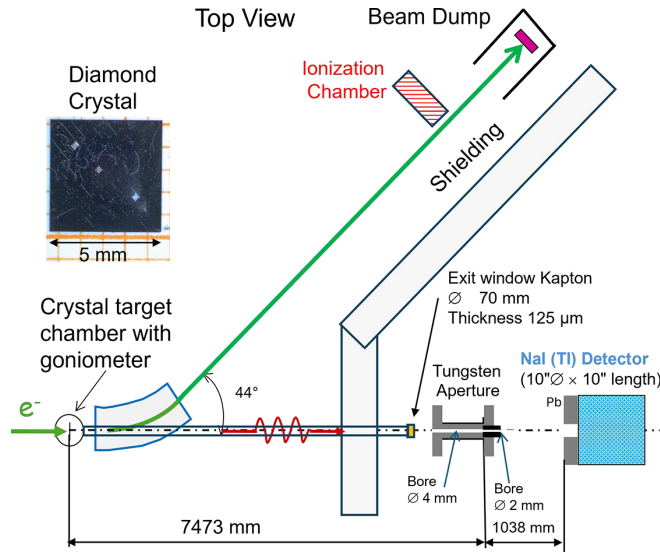


FIG. 3. Experimental setup at MAMI, not to scale. Radiation can be observed at virtual collinear geometry of the electron beam direction and the sodium iodide NaI(Tl) radiation detector. The inset depicts the undulator crystal with the position of three rectangular $250 \mu\text{m} \times 250 \mu\text{m}$ ToF-SIMS craters.

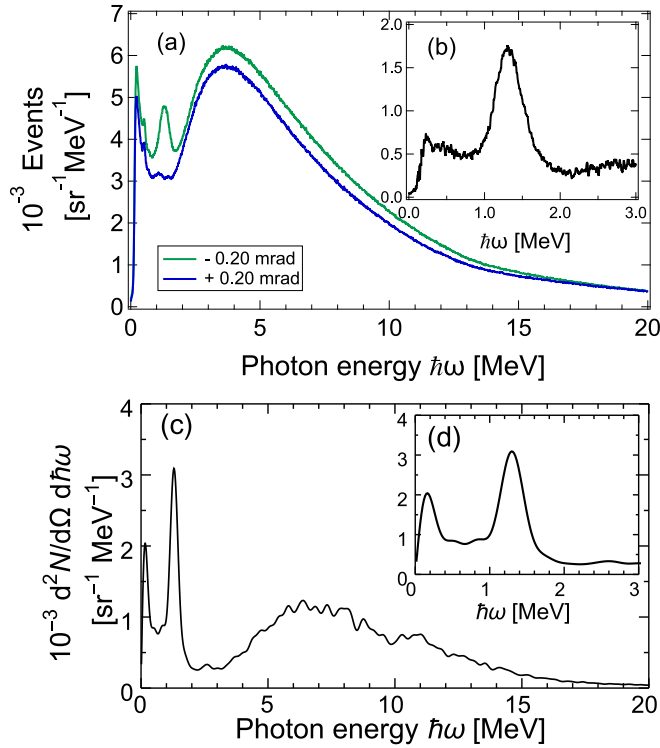


FIG. 4. (a) Experimental spectra of the undulator chip per electron, including the 182 μm thick backing crystal. Spectra taken with the NaI(Tl) detector at a typical beam current of 3.95 pA. Spectrum in green color for detuning the aperture from z direction by $\theta_x = -0.2$ mrad, and in blue color by $+0.2$ mrad. Both are dominated by channeling radiation of the backing crystal. (b) Low-energy part of difference spectrum. Background spectrum taken at $\theta_x = +0.2$ mrad aperture position (blue) subtracted from spectrum taken at -0.2 mrad (green). (c), (d) Monte Carlo simulated spectra per electron without a backing crystal, including scattering off atoms and electrons comprising the crystal [17,32]. Ideal sinusoidal boron doping profile and infinitesimal small aperture size assumed, beam divergence $\sigma_x = \sigma_y = 0.015$ mrad. Mean of 400 single simulations.

Figures 4(c) and 4(d) depict Monte Carlo simulated spectra under idealized conditions. The calculations are based on the formalism described in Appendix B. The bremsstrahlung contribution was estimated from Fig. 9(c) of Ref. [17] to be small and has been neglected. With some care in mind, the simulated spectrum Fig. 4(d) will be compared with the experimentally observed one of Fig. 4(b). The peak energy from the simulation calculation of 1.28 MeV is close to the measured one of 1.30 MeV. The experimentally observed spectral width is broader, and the total intensity is significantly lower than predicted by simulation. The Bragg-diffraction image of Fig. 2(b) may indicate that the amplitude decreases by relaxation of the stress, probably by misfit dislocations [33], a fact not taken into account in our simulation calculation. In addition, an infinitesimal small aperture was assumed, which is also unrealistic, not to mention that the lattice expansion constant of the modified Vegard's law could be different, and that also the simulation model has systematic errors.

We add that a peak was also observed when the crystal was aligned into the (111) plane.

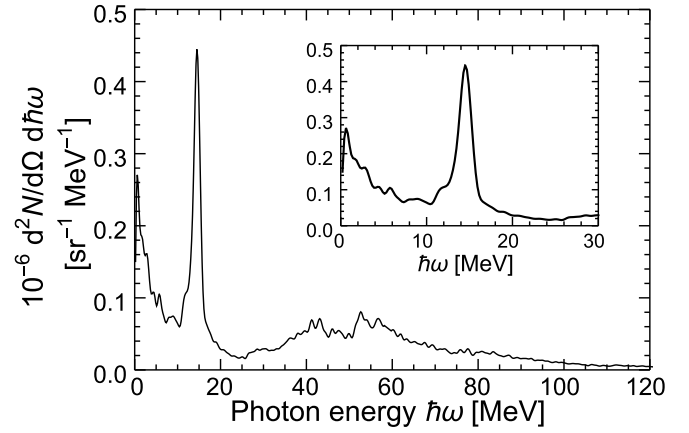


FIG. 5. Simulated photon spectrum per electron for a sinusoidal boron doping profile at a beam energy of 3.0 GeV. Period length $\lambda_U = 5$ μm , minimum barrier height $U_B = 9.0$ eV, amplitude $A_U = 0.656$ $\text{\AA}$, undulator parameter $K = 0.48$, relaxation length $L_A = \infty$, and number of periods $N_U = 12$. An infinitesimal small aperture was assumed positioned at $\theta_x = \delta = -0.0824$ mrad and $\theta_y = 0$. Beam divergence $\sigma_x = \sigma_y = 0.06$ mrad. Mean of 200 single simulations.

For applications one has to cope with the unavoidable and rather intense channeling radiation distribution tail [34]. However, it can be minimized by optimizing the boron doping profile and the number of periods [see Fig. 7(b) in Appendix B]. To cope with the tail, difference measurements must be performed by detuning the photon peak energy or varying the observation angle. While a detuning off the resonance under investigation has a drastic effect, a shift of the continuum energy has only a minor effect on the intensity of high-energy parasitic resonances.

V. OUTLOOK

As shown in Appendix B, at the MAMI facility with a beam energy of 855 MeV narrow-band and highly directional photon beams can be provided in a wide photon energy range. Such beams are useful for detector calibration purposes with tailored undulators. However, for nuclear resonance fluorescence experiments the intensity is too low in contrast to various photonuclear reactions in the giant resonance domain. For the latter, photons with energies on the order of 15 MeV are required. According to Eq. (1), an as small as possible undulator period λ_U should be chosen to keep the beam energy of the electron accelerator as low as possible. However, from the viewpoint of the peak intensity, there exist severe restrictions on the magnitude of λ_U and by interference phenomena between the channeling and undulator radiation, as pointed out in Appendix B. The following estimates are performed for a dedicated 3 GeV accelerator to illuminate figures of merits and limitations of the novel radiation source, free of restrictions imposed by existing facilities like the 1.6 GeV facility of MAMI B or 12 GeV Continuous Electron Beam [35] at Thomas Jefferson National Accelerator Facility.

Results of simulation calculations are shown in Fig. 5. The main feature is the very intense peak at a photon energy of 14.5 MeV with a full width of half maximum of 1.9 MeV. The energy integrated peak intensity amounts to

about $0.6 \times 10^6 \text{ sr}^{-1}$ and electron. Estimations with Eq. (1) show that for $(\gamma\theta)^2 \simeq 0.03 \text{ rad}^2$, the peak energy shift is small compared with its half-width. With the fraction of the intensity located in an angular cone with a radius of about 0.03 mrad, the corresponding solid angle is $3 \times 10^{-9} \text{ sr}$, the integrated γ -ray flux amounts to 1.8×10^{-3} per electron. At a beam current of 100 μA , totally 1.1×10^{12} photons per second would be emitted in the peak. The on-target photon flux is orders of magnitude larger than for Compton-backscattering sources (see Table 10 of Ref. [4]), however, with a high-energy photon tail. The principle to cope with it has been described at the end of Sec. IV.

The time structure can be controlled by the electron beam. Some applications may benefit from the fact that the emitted γ -ray beam is expected to be linearly polarized. With such a beam, a number of experiments in fields like basic nuclear research, technical applications, and medicine are conceivable with small sample sizes since even in 10 m distance the γ -ray beam spot has a radius of only 0.3 mm.

The heat load at a 100 μm thick diamond target plate at a beam current of 100 μA can be estimated to be about 10 W, which seems to be manageable. The total power of the electron beam amounts to 300 kW. If energy recovery would be feasible, the power consumption and the radioactive waste in the beam dump can be reduced.

VI. CONCLUSION

A four-period diamond superlattice was fabricated via chemical vapor deposition with a sinusoidal boron doping profile. The accompanied periodic variation of the lattice constant resulted in sinusoidally deformed (110) planes with a period length of 5.0 μm and an amplitude of 0.098 nm. A channeling experiment was performed with the 855 MeV electron beam of the Mainz Microtron MAMI accelerator facility. A clear peak was observed with a large sodium iodide scintillation detector at a photon energy of 1.30 MeV. Monte Carlo simulation calculations, assuming an ideal sinusoidal undulator profile, reproduce well the photon peak energy. However, the measured linewidth and intensity seem, in comparison, to be broadened and reduced, respectively, for which explanations have been discussed.

With the existing scientific accelerator facility MAMI, narrow-band photon beams with energies below 6 MeV could be provided. Higher photon energies require higher electron energies to achieve optimal intensities. Simulation calculations were performed for an intense 14.5 MeV γ -ray beam with 3 GeV electrons.

The photon energy spectra resemble the radiation characteristics known from the magnetic undulator theory, featuring a strong fundamental peak, but also an unavoidable high-energy tail from channeling radiation. To cope with it, the electron beam energy or the observation direction must be varied. The high directionality, combined with an intensity orders of magnitude larger than that for Compton-backscattering sources (see Table 10 of Ref. [4]) should be beneficial for potential applications with rather small target samples. Many of the fields addressed in Ref. [4] are suitable for applications in basic nuclear research, technical applications, or even medicine.

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D.E.: boron-doped diamond growth; T.N.T.C.: diamond preparation; P.S., L.K., T.N.T.C., and R.D.: crystal characterization; H.B., W.L., and T.N.T.C.: model development; R.D., P.E., S.B., J.B., and T.N.T.C.: ESRF beamtime; W.L., P.K., R.D., and T.N.T.C.: MAMI beamtime; H.B.: editor.

DATA AVAILABILITY

The data that support the findings of this article are openly available on request to one of the contact authors, embargo periods may apply.

APPENDIX A: SUPERLATTICE DESIGN AND FABRICATION

The design profile of the boron doping in [100] direction is of sinusoidal shape with minimum and maximum boron contents $x_{b,\min} = c_{b,\min}/n_C = 5.67 \times 10^{-4}$ and $x_{b,\max} = c_{b,\max}/n_C = 56.7 \times 10^{-4}$. The corresponding boron concentrations are $c_{b,\min} = 1.0 \times 10^{20} \text{ cm}^{-3}$ and $c_{b,\max} = 10.0 \times 10^{20} \text{ cm}^{-3}$, respectively, and the density of carbon atoms for diamond is $n_C = 1.763 \times 10^{23} \text{ cm}^{-3}$. As function of the z coordinate the boron content reads for the first half-period $x_b(z) = x_{b,\min} + (x_{b,\max} - x_{b,\min})/2 \times (1 - \cos[2\pi z/\lambda_U])$, $0 \leq z \leq \lambda_U/2$. The continuation to $\lambda_U/2 < z \leq \lambda_U$ can be obtained by symmetry considerations.

The lattice expansion for the “atomic volume interpolation” (see Fig. 1 of Ref. [26]), also called linear “modified Vegard’s law,” reads $\Delta d_{110}/d_{110}(z) = k \times x_b$, with the slope constant $k = 0.0962$. A differential equation $dx_b/dz = -k \times x_b(z/\sqrt{2})/2$ must be solved to obtain the nominal bending of the (110) channel with $x_b(z \rightarrow 0) = 0$. The angle at the entrance is $\delta_0 = dx_b/dz(z \rightarrow 0) = -0.0272 \text{ mrad}$, caused by the residual boron doping. The solution is schematically shown in Fig. 6.

A periodically bent (110) channel results with $\lambda_U = \sqrt{2} \times 3.54 \mu\text{m} = 5.0 \mu\text{m}$, which is schematically shown in Fig. 6. It defines the (x', z') coordinate system with the z' axis through the turning points of the derivative, rotated clockwise by an angle $\delta = \delta_0 - \delta_U = -0.150 \text{ mrad}$, $A_U = 0.977 \text{ \AA}$, $\delta_U = 2\pi/\lambda_U \times A_U = 0.123 \text{ mrad}$, with respect to the nominal [110] direction of the undoped diamond backing crystal.

When fabricating undulator devices, attention must be paid to both the quality of the doped overlayers and the quality of diamond substrate. Our application requires single-crystal diamond substrates with the main surface orientation (100), with a miscut angle of 2° within one surface and with highly perfect bulk and surface crystal quality. In addition, such diamond plates should be available with large areas (several mm^2) free of extended defects such as dislocations. The diamond surface also plays an important role for the quality of the overgrown layers on it; therefore, it must be as flat

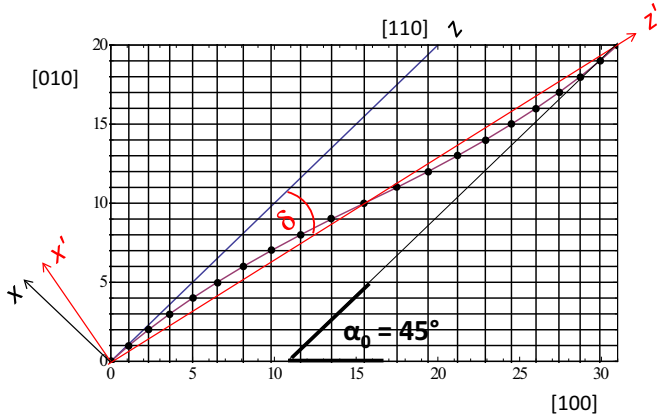


FIG. 6. Effect of a periodic variation of the lattice constant. A superlattice (undulator) crystal originates as shown by the full line with black dots for one period. The effect of the tetragonal distortion of the equilibrium cubic unit cell has been described by M. B. H. Breese [33]. The electron beam enters in z direction with an angle $\delta_0 = -0.0272$ mrad with respect of the $[110]$ direction of the plane backing crystal. The z' direction is the undulator direction. The two coordinate systems (x, z) and (x', z') are interconnected by a rotation transform with an angle $\delta = -0.150$ mrad. Planes are formed perpendicular to the plane of drawing. Figure taken from Ref. [17].

as possible. With special mechanical-chemical polishing, we reach the flat surface of less than 1 nm rms. Our final choice is high-crystalline-quality high-pressure-high-temperature type IIa substrates with the size around $5 \times 5 \text{ mm}^2$. The thickness of the diamond substrate varies from 80 to $270 \mu\text{m}$ from one side to the other, due to the miscut angle of 2° . The diffraction RCI technique shows not many defects present in the bulk: some dislocations, no stacking faults, no growth sector boundaries, no inclusion, and very few defects introduced by surface processing.

For the growth of the boron-doped diamond layers, the diamond sample was first subjected to a triacid cleaning process consisting of 1 volume of HClO_4 , 4 volumes of HNO_3 , and 3 volumes of H_2SO_4 for 1 h under boiling conditions. This step effectively removes residual graphitic surface layers. The sample was then rinsed with acetone, followed by alcohol and isopropyl alcohol. Subsequently, the sample was loaded into a microwave-assisted CVD reactor for diamond growth. The reactor plasma was ignited under a hydrogen atmosphere at a pressure of 44 mbar and a power of 250 W. The sample was exposed to this plasma for 1 h to ensure uniform temperature distribution across both the sample and the reactor interfaces.

The growth process itself is a key innovation to achieve the desired doping profile required for the specific application. A tailored dilution stage, with precise control of the mass flow controllers, was employed to ensure a sinusoidal boron doping pattern in the gas phase. During the growth phase, a gas flow of 100 sccm of H_2 and 4 sccm of CH_4 was maintained, with a variable B_2H_6 concentration injected into the gas mixture. Based on established calibration curves, the expected boron doping level in the diamond ranges from 1×10^{20} to $10 \times 10^{20} \text{ cm}^{-3}$. Temperature control was achieved using a pyrometer, maintaining an average temperature of 850°C throughout

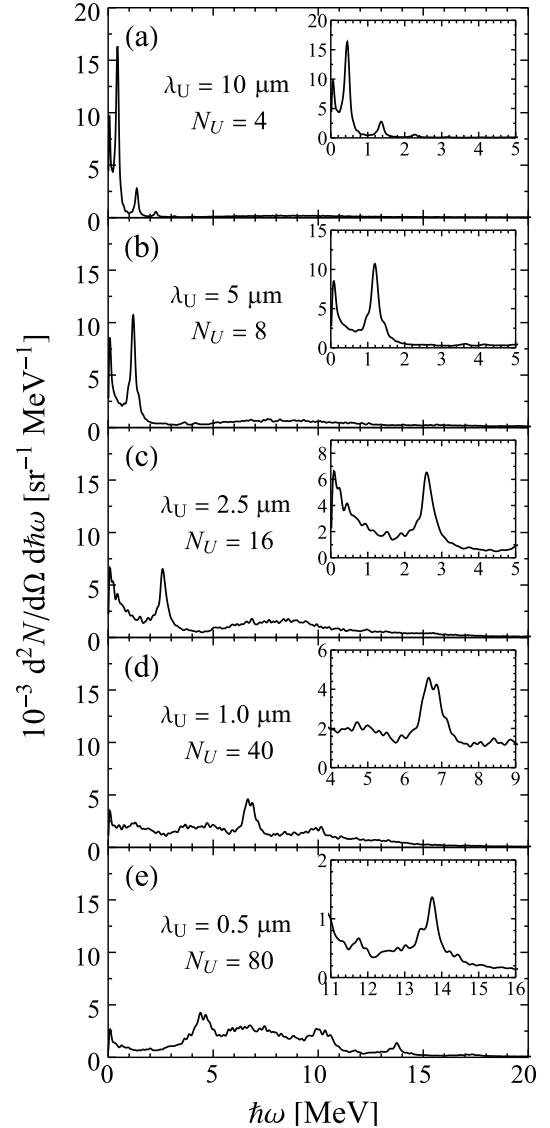


FIG. 7. Simulated photon spectrum per electron for a sinusoidal boron doping profile at a beam energy of 855 MeV. Both period length λ_U and number of periods N_U vary with $\lambda_U N_U = 40 \mu\text{m}$ a constant, minimum barrier height $U_B = 8.5 \text{ eV}$, and minimum bending radius $R_{\min} = 2.632 \text{ mm}$. Undulator amplitudes A_U are $9.626 \text{ \AA}$ [panel (a)], $2.406 \text{ \AA}$ [panel (b)], $0.602 \text{ \AA}$ [panel (c)], $0.0963 \text{ \AA}$ [panel (d)], and $0.0240 \text{ \AA}$ [panel (e)]. Undulator parameters K are 1.0130 [panel (a)], 0.5063 [panel (b)], 0.2531 [panel (c)], 0.1013 [panel (d)], and 0.0506 [panel (e)]. Beam divergence $\sigma_x = \sigma_y = 0.06$ mrad. Mean of 200 single simulations.

the process. Considering the growth rates, each doping cycle lasted for 6015 s with the growth rate of 0.58 nm/s .

APPENDIX B: MONTE CARLO SIMULATION CALCULATIONS

The Monte Carlo simulation code described in Ref. [17] holds only for triangular doping profiles resulting in a constant bending radius for each half-period with opposite signs. For this work, therefore, it was reformulated for sinusoidal shapes avoiding approximations.

The starting point is the equation of motion (see Eq. (2.78) of Ref. [36]) in the noninertial undulating reference frame:

$$pv \frac{dx'^2}{dz'^2} = -\frac{du(x')}{dx'} - \frac{pv}{R(z')} = -\frac{dU(x', z')}{dx'}, \quad (\text{B1})$$

$$U(x', z') = u(x') + \frac{pv}{R(z')}x', \quad (\text{B2})$$

$$1/R(z') = -(1/R_{\min}) \sin(2\pi z'/\lambda_U). \quad (\text{B3})$$

In Eq. (B1), $u(x')$ is the planar (110) potential in the (x', z') coordinate system, defined in Fig. 6, which periodically repeats with the interplanar distance d_p . The additional term $pv/R(z')$ describes according to Eq. (B3) the centrifugal force with $R(z')$ the bending radius with $0 < 1/R_{\min} = A_U(2\pi/\lambda_U)^2$ at which $R_{\min}$ is its minimum value, and A_U the undulator amplitude. It is a function of the longitudinal coordinate z' . In addition, are $pv = \beta^2 \gamma m_e c^2$, with $m_e c^2$ the rest mass of the electron, γ the Lorentz factor, and $\beta = v/c = \sqrt{1 - 1/\gamma^2}$ the reduced speed v of the electron.

With the second equal sign in Eq. (B1), formally a potential $U(x', z')$, Eq. (B2), has been introduced. A particle captured in the pocket, whose depth varies with z' , is steered by it and performs, in addition to the channeling oscillation, the wanted undulator oscillation.

The simulation calculation has been performed for the first interval $\Delta z = 100 \text{ \AA}$ by numerically solving Eq. (B1) with the randomly determined initial values $x(0)$ and $\vartheta_x(0) = dx'/dz'(0)$. In the iteration process, the scattering angle change $\Delta\vartheta_x$ by collisions with atoms and also electrons, notice that Ref. [17] is based upon Ref. [32] in which both interactions have been treated, was calculated for the n th interval with constant thickness Δz . For the $(n+1)$ th interval, Eq. (B1) was solved with the modified initial values $\vartheta_x((n+1)\Delta z) = \vartheta_x(n\Delta z) + \Delta\vartheta_x(\Delta z)$ and $x((n+1)\Delta z) = x(n\Delta z)$, whereby n denotes the exit values of the preceding numerical solution.

Transformation into the inertial (x, z) system is done by a rotation with the angle $0 < \delta = A_U 2\pi/\lambda_U \ll 1$ resulting approximately in $x = x' - z'\delta + A_U \sin(2\pi/\lambda_U \times z')$ and $z = z'$. The instantaneous angle of the trajectory must be corrected by a term $\delta \times (1 - \cos(2\pi/\lambda_U \times z'))$. Alternatively, the differential equation (B1) can be transformed into the (x, z)

system resulting in

$$pv \frac{dx^2}{dz^2} = -\frac{du(x + z \times \delta - A_U \sin(2\pi/\lambda_U \times z))}{dx}. \quad (\text{B4})$$

A frequency-modulation-like term appears that might result in Fig. 5 in the third harmonic and the feature at 56 MeV.

For applications, the photon energy $\hbar\omega$ is the primary quantity for which a peak intensity as high as possible, a linewidth as narrow as possible, and total background radiation as low as possible must be found. In the following, the procedure will be sketched to find proper parameters. With Eqs. (B2) and (B3), a minimum barrier height $U_B = U(x'_{\max}, \lambda_U/4) - U(x'_{\min}, \lambda_U/4)$ has been introduced with $x'_{\max}$ and $x'_{\min}$, both functions of $pv/R_{\min}$. Solving for the latter at a given U_B results in $pv/R_{\min} = 2\pi\beta^2 m_e c^2 K/\lambda_U$. The right-hand side has been obtained by the replacement $1/R_{\min} = A_U(2\pi/\lambda_U)^2$ and elimination of A_U with the undulator parameter $K = \gamma \times A_U \times 2\pi/\lambda_U$. Since the left-hand side is a constant, it follows that K and λ_U are strictly correlated, independent of γ . Intensities of the peak and the high-energy tail are rather sensitive functions of U_B . For a somewhat optimized $U_B = 8 \text{ eV}$, a $pv/R_{\min} = 0.34 \text{ MeV}/\mu\text{m}$ is obtained, and for a reasonable large $K = 0.53$, a $\lambda_U = 5.0 \mu\text{m}$ results. Now, γ can be calculated with the aid of Eq. (1) for the required $\hbar\omega$. The only remaining parameter is the number of periods N_U that must be optimized by simulation calculations. Practical limits originate, in addition to scattering, also from the amplitude relaxation L_A , which is a material constant. Since it is unknown, we assumed $L_A = \infty$.

Figure 7 shows spectra for a beam energy of 855 MeV at λ_U and N_U both variable with $\lambda_U N_U = 40 \mu\text{m}$ a constant. The peak energy varies with the undulator period as expected; however, in panels (d) and (e) the total background intensity may be too large for any application. The structures may be interpreted as interference phenomena between undulator and channeling radiation. A good compromise may be $\lambda_U = 5 \mu\text{m}$ and $N_U = 8$ [panel (b)], which fixes the photon peak energy somewhere around $\hbar\omega = 1.3 \text{ MeV}$. What has been exemplified here holds figuratively for other scenarios, in particular, also for the experiments with $\text{Si}_{1-x}\text{Ge}_x$ undulator crystals at a period length of $0.43\text{--}0.44 \mu\text{m}$ [23,24].

The code runs on Wolfram Mathematica 14.3, executed on a personal computer. It delivers useful results in reasonable real time of about 10 min.

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